

Rika™ Source Plasma System

| <u>Country</u> | <u>Pat. No.</u> |
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| Australia | 2018254601 |
| China | ZL2023300225838 |
| China | CN110709118 |
| Colombia | 40710 |
| European Patent Convention | 3860677 |
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| South Korea | 10-2574345 |
| United States | 11980707 |
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